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Docket No.: 20506/0203830-US0 (PATENT)

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:

Euijoon Yoon et al.

Application No.: Not Yet Assigned

Confirmation No.: N/A

Filed: Concurrently Herewith

Art Unit: N/A

For: GROWTH METHOD FOR NITRIDE

SEMICONDUCTOR EPITAXIAL LAYERS

Examiner: Not Yet Assigned

## **CLAIM FOR PRIORITY AND SUBMISSION OF DOCUMENTS**

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Dear Sir:

Applicant hereby claims priority under 35 U.S.C. 119 based on the following prior foreign application filed in the following foreign country on the date indicated:

CountryApplication No.DateRepublic of Korea10-2003-0046119July 8, 2003

A certified copy of the aforesaid Korean Patent Application was received by the International Bureau on July 26, 2004 during the pendency of International Application No. PCT/KR2004/001665. A copy of Form PCT/IB/304 is enclosed.

Dated: January 6, 2006

Respectfully submitted

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